

DEVICE
PERFORMANCE
SPECIFICATION

KODAK KAF-8300CE

Image Sensor

3326 (H) x 2504 (V)
Full-Frame CCD Color Image Sensor
With Square Pixels for Color Cameras

October 11, 2004
Revision 1.0

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SUMMARY SPECIFICATION

KODAK KAF-8300 Image Sensor

3326 (H) x 2504 (V) Full-Frame CCD

Color Image Sensor



Description

The KAF-8300CE is a 22.5mm diagonal (Type 4/3) high performance color full-frame CCD (charge-coupled device) image sensor designed for a wide range of color image sensing applications including digital imaging. Each pixel contains blooming protection by means of a lateral overflow drain thereby preventing image corruption during high light level conditions. Each of the 5.4 μ m square pixels are patterned with an RGB mosaic color filter with overlying microlenses for improved color response and reproduction. The microlens offset is designed for a 6 $^\circ$ -principle ray along the sensor diagonal. A border of buffer and light-shielded pixels surrounds the photoactive pixels.

This device is manufactured in Rochester, NY by The Eastman Kodak Company – Image Sensor Solutions.

All parameters above are specified at T = 60°C and a data rate of 28MHz.

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Parameter	Typical Value
Architecture	Full Frame CCD; with Square Pixels
Total Number of Pixels	3448 (H) x 2574 (V) = approx. 8.90M
Number of Effective Pixels	3358 (H) x 2536 (V) = approx. 8.6M
Number of Active Pixels	3326 (H) x 2504 (V) = approx. 8.3M
Pixel Size	5.4 μ m (H) x 5.4 μ m (V)
Imager Size	22.5mm (diagonal)
Chip Size	19.7mm (H) x 15.04mm (V)
Aspect Ratio	4:3
Saturation Signal	25.5 K e ⁻
Charge to Voltage Conversion	23 μ V/e ⁻
Quantum Efficiency (RGB)	0.32, 0.40, 0.32
Total Sensor Noise	16 e ⁻
Dark Signal	200 e ⁻ /s
Dark Current Doubling Temperature	6.3 $^\circ$ C
Linear Dynamic Range	64.4 dB
Linearity Error at 12 $^\circ$ C	+/- 8%
Charge Transfer Efficiency	0.99999
Blooming Protection @1ms integration time	1000x saturation exposure
Maximum Data Rate	28 MHz
Package	32-pin CerDIP, 0.070" pin spacing
Cover Glass	Clear with shadow mask

DEVICE DESCRIPTION

Architecture

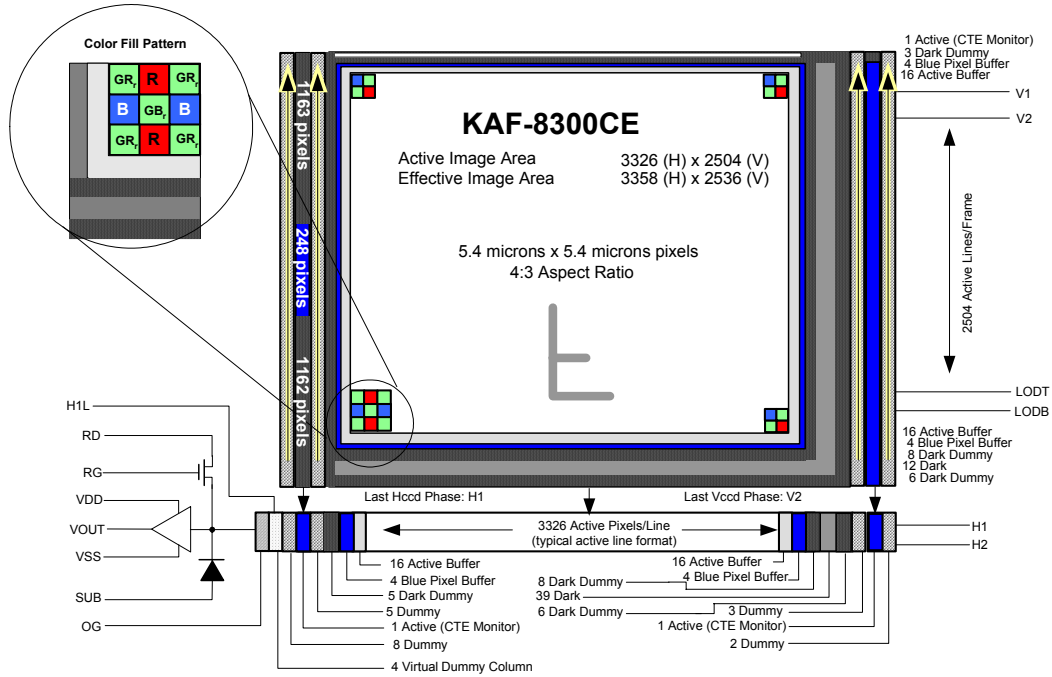


Figure 1 - Sensor Architecture

Dark Reference Pixels

Surrounding the periphery of the device is a border of light shielded pixels creating a dark region. Within this dark region, exist light shielded pixels that include 39 trailing dark pixels on every line. There are also

12 full dark lines at the start of every frame. Under normal circumstances, these pixels do not respond to light and may be used as a *dark reference*.

Dark Dummy Pixels

Within the dark region some pixels are in close proximity to an active pixel, or the light sensitive regions that have been added for manufacturing test purposes, (*CTE Monitor*). In both cases, these pixels can scavenge signal depending on light intensity and wavelength. These pixels should not be used as a dark reference. These pixels are called *dark dummy pixels*.

Within the dark region, dark dummy pixels have been identified. There are 5 leading and 14 (6 + 8) trailing dark pixels on every line. There are also 14 (6 + 8) dark dummy lines at the start of every frame along with 3 dark dummy lines at the end of each frame.

Dummy Pixels

Within the horizontal shift register there are 13, (8 + 5), leading and 5, (2 + 3), trailing additional shift phases that are not electrically associated with any columns of pixels within the vertical register. These pixels contain only horizontal shift register

dark current signal and do not respond to light and therefore, have been designated as *dummy pixels*. For this reason, they should not be used to determine a dark reference level.

Virtual Dummy Columns

Within the horizontal shift register there is 4 leading shift phases that are not physically associated with a column of pixels within the vertical register. These pixels contain only horizontal shift register

dark current signal and do not respond to light and therefore, have been designated as *virtual dummy columns*. For this reason, they also should not be used to determine a dark reference level.

Active Buffer Pixels

Sixteen buffer pixels adjacent to the blue pixel buffer regions contain a RGB mosaic color pattern. This region is classified as *active buffer pixels*. These pixels are light

sensitive but they are not tested for defects and non-uniformities. The response of these pixels will not be uniform.

Blue Pixel Buffer

Four buffer pixels adjacent to any leading or trailing dark reference regions contain a blue filter. This region is classified as a *blue pixel buffer*. These pixels are light

sensitive but they are not tested for defects and non-uniformities. The response of these pixels will not be uniform.

CTE Monitor Pixels

Within the horizontal dummy pixel region two light sensitive test pixels (one each on the leading and trailing ends) are added and within the vertical dummy pixel region one light sensitive test pixel has been added. These *CTE monitor pixels* are

used for manufacturing test purposes. In order to facilitate measuring the device CTE, the pixels in the CTE Monitor region in the horizontal and vertical portion is coated with blue pigment.

Image Acquisition

An electronic representation of an image is formed when incident photons falling on the sensor plane create electron-hole pairs within the device. These photon-

induced electrons are collected locally by the formation of potential wells at each photogate or pixel site. The number of electrons collected is linearly

dependent on light level and exposure time and non-linearly dependent on wavelength. When the pixel's capacity is reached, excess electrons are discharged into the lateral overflow drain to prevent crosstalk or 'blooming'. During the integration period, the V1 and V2 register clocks are held at a constant (low) level.

Charge Transport

The integrated charge from each photogate is transported to the output using a two-step process. Each line (row) of charge is first transported from the vertical CCD's to a horizontal CCD register using the V1 and V2 register clocks. The horizontal CCD is presented a new line on the falling edge of V2 while H1 is held high. The horizontal CCDs then transport each line, pixel by

pixel, to the output structure by alternately clocking the H1 and H2 pins in a complementary fashion. A separate connection to the last H1 phase (H1L) is provided to improve the transfer speed of charge to the floating diffusion. On each falling edge of H1 a new charge packet is dumped onto a floating diffusion and sensed by the output amplifier.

Horizontal Register

Output Structure

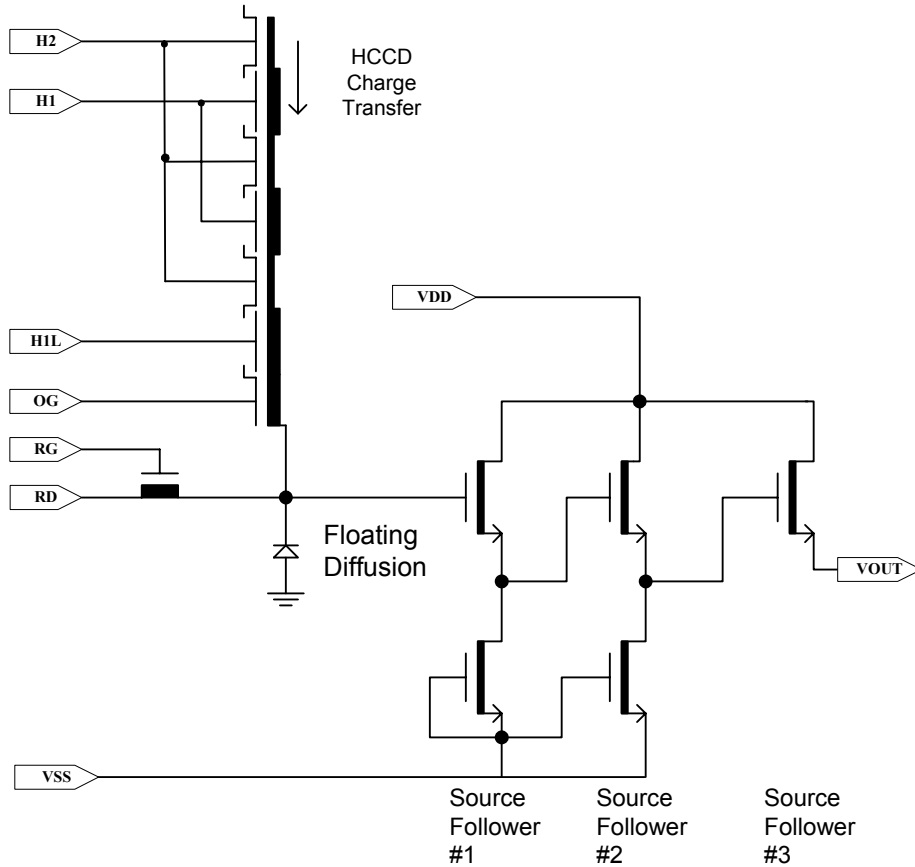


Figure 2 - Output Architecture

Charge presented to the floating diffusion (FD) is converted into a voltage and is current amplified in order to drive off-chip loads. The resulting voltage change seen at the output is linearly related to the amount of charge placed on the FD. Once the signal has been sampled by the system electronics, the reset gate (RG) is

clocked to remove the signal and FD is reset to the potential applied by reset drain (RD). Increased signal at the floating diffusion reduces the voltage seen at the output pin. To activate the output structure, an off-chip load must be added to the VOUT pin of the device. See Figure 3.

Output Load

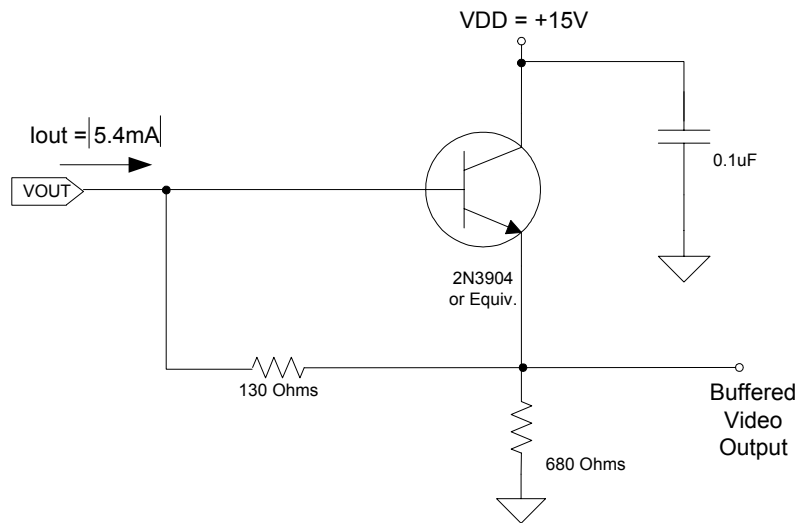
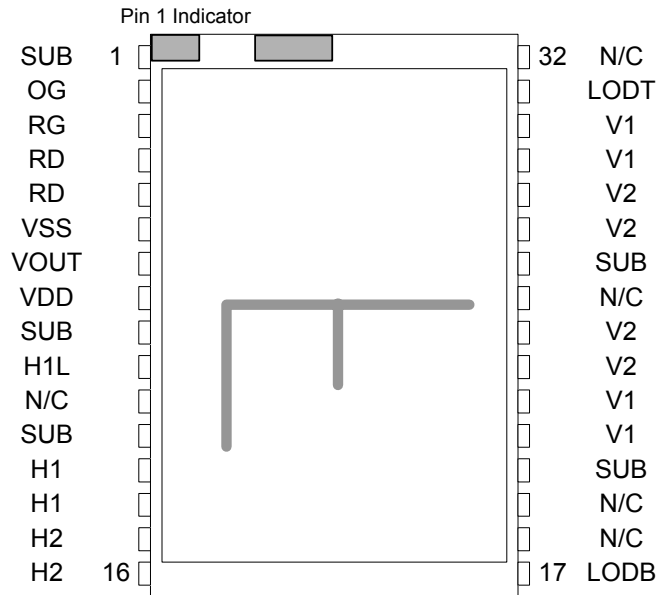


Figure 3 – Recommended Output Structure Load Diagram

Component values may be revised based on operating conditions and other design considerations.

Physical Description

Pin Description and Device Orientation



Pin	Name	Description	Pin	Name	Description
1	SUB	Substrate	32	N/C	No Connection
2	OG	Output Gate	31	LODT	Lateral Overflow Drain Top
3	RG	Reset Gate	30	V1	Vertical Phase 1
4	RD	Reset Drain Bias	29	V1	Vertical Phase 1
5	RD	Reset Drain Bias	28	V2	Vertical Phase 2
6	VSS	Output Amplifier Return	27	V2	Vertical Phase 2
7	VOUT	Output	26	SUB	Substrate
8	VDD	Output Amplifier Supply	25	N/C	No Connection
9	SUB	Substrate	24	V2	Vertical Phase 2
10	H1L	Horizontal Phase 1, Last Gate	23	V2	Vertical Phase 2
11	N/C	No Connection	22	V1	Vertical Phase 1
12	SUB	Substrate	21	V1	Vertical Phase 1
13	H1	Horizontal Phase 1	20	SUB	Substrate
14	H1	Horizontal Phase 1	19	N/C	No Connection
15	H2	Horizontal Phase 2	18	N/C	No Connection
16	H2	Horizontal Phase 2	17	LODB	Lateral Overflow Drain Bottom

Note:

Wherever possible, all N/C pins (11, 18, 19, 25, 32) should be connected to GND (0V).

Figure 4 – Package Pin Description

PERFORMANCE

Image Performance Operational Conditions

Description	Condition - Unless otherwise noted	Notes
Readout Time (t_{readout})	370.36 msec	Includes $t_{\text{Voverclock}}$ & $t_{\text{Hoverclock}}$
Integration time (t_{int})	33 msec	
Horizontal clock frequency	28 MHz	
Light source (LED)	Refer to KAF-8300CE Test Plan	Section 2.4
Mode	Flush – integrate – readout cycle	

Imaging Performance Specifications

Description	Symbol	Min.	Nom.	Max.	Units	Notes	Sample Plan ¹⁸
Minimum Column	MinColumn	575			mV	1	die
Linear Saturation Signal	N_{sat}^-	25.5K			e^-	1,3	design
Charge to Voltage Conversion	Q-V	22.5	23		$\mu\text{V}/e^-$		design
Sensitivity	red, green, blue	Rresp Gresp Bresp	260 442 230	420 638 420	mV mV mV	4	die die die
	Off-band Response						
	Green inband,						
Red response	Gr_Gresp	362		630	mV		die
Blue response	Gr_Rresp	0		130	mV		die
Red inband,							
Green response	Gr_Bresp	0		260	mV		die
Blue response	Rd_Rresp	180		430	mV	4	die
	Rd_Gresp	0		120	mV		die
Blue inband,							
Red response	Rd_Bresp	0		45	mV		die
Green response	Bl_Bresp	90		420	mV		die
	Bl_Rresp	0		40	mV		die
	Bl_Gresp	0		120	mV		die

Description	Symbol	Min.	Nom.	Max.	Units	Notes	Sample Plan ¹⁸
Linearity Error	LeLow10	-10		10	%	2,5,6	die
	LeLow33	-10		10	%	2,5,6	die
	LeHigh	-10		10	%	2,5	die
Linearity Balance	Red_Bal	-14	6.4	14	%	2, 6	die
	Blu_Bal	-8	0.2	8	%	2, 6	die
Photo Response Non-Uniformity	R_PRNU			15	%p-p	7	die
	G_PRNU			15	%p-p	7	die
	B_PRNU			15	%p-p	7	die
High Frequency Noise	R_Nois			2	%rms		die
	GRr_Nois			2	%rms		die
	GBr_Nois			2	%rms		die
	B_Nois			2	%rms		die
Dark Signal (Active Area Pixels)	AA_DarkSig			200	e-/s	8	die
Dark Signal (Dark Reference Pixels)	DR_DarkSig			200	e-/s	8	die
Readout Cycle Dark Signal	Dark_Read			15	mV/s		die
Flush Cycle Dark Signal	Dark_Flush		43	90	mV/s		die
Dark Signal Non-Uniformity	DSNU		1.30	3	mVp-p	9	die
	DSNU_Step		0.14	0.5	mV p-p	9	die
	DSNU_H		0.4	1.0	mVp-p	9	die
Dark Signal Doubling Temperature	ΔT		5.8		°C		design
Dark Reference Difference, Active Area	DarkStep	-3.5	0.15	3.5	mV		die
Total Noise	Dfld_noi			1.08	mV	10	die
Total Sensor Noise	N		16		e ⁻ rms	19	design
Linear Dynamic Range	DR		64.4		dB	11	design
Red-Green Hue Shift	RGHueUnif			10	%	12	die
Blue-Green Hue Shift	BGHueUnif			12	%	12	die
GRr/GBr Hue Uniformity	GrGbHueUnf			7	%	12	die
Green Light GRr/GBr Hue Uniformity	Gr_GHueUnf			9	%		die
Low Hue Uniformity	RGLoHueUnf			12	%		die
	BGLoHueUnf			10	%		die
Streak/Spot	GrnStreak			40	%		
	RedStreak			20	%		
	BluStreak			20	%		

Description	Symbol	Min.	Nom.	Max.	Units	Notes	Sample Plan ¹⁸
Horizontal Charge Transfer Efficiency	HCTE	0.999990	0.999995			13, 21	die
Vertical Charge Transfer Efficiency	VCTE	0.99997	0.999999		%	21	die
Blooming Protection	X_b	1000			x Esat	14	design
Vertical Bloom on Transfer	VBloomF	-20		20	mV		die
Horizontal Crosstalk	H_Xtalk	-20		20	mV		die
Horizontal Overclock Noise	Hoclk_noi	0		1.08	mV		die
Output Amplifier Bandwidth	f _{-3dB}	88		159	Mhz	6,16	die
Output Impedence, Amplifier	R _{OUT}	100		180	Ohms		die
Hclk Feedthru	V _{hft}			70	mV	17	die
Reset Feedthru	V _{rtt}	500	710	1000	mV		design
Local Green Difference							
white light, min	W_GNU_Min			4	%		die
white light, max	W_GNU_Max			6	%		die
green light, min	Gr_GNU_Min			4	%		die
green light, max	Gr_GNU_Max			4	%		die
red light, min	R_GNU_Min			65	%		die
red light, max	R_GNU_Max			65	%		die
blue light, min	B_GNU_Min			40	%		die
blue light, max	B_GNU_Max			40	%		die
Chroma Test	UL_Chroma			7	%		die
	UR_Chroma			7	%		die
	LL_Chroma			7	%		die
	LR_Chroma			7	%		die
Hue Test	UL_UR_Hue			6	%		die
	UL_LR_Hue			6	%		die
	UL_LL_Hue			6	%		die
	UR_LR_Hue			6	%		die
	UR_LL_Hue			6	%		die
	LR_LL_Hue			6	%		die

Notes:

1. Increasing output load currents to improve bandwidth will decrease these values.
2. Specified from 12C to 60C.
3. Saturation signal level achieved while meeting Le specification. Specified from 0°C to 40°C.
4. Refer to KAF-8300CE Test Plan.

5. Worst case deviation, (from 10mV to V_{sat} min), relative to a linear fit applied between 0 and 500mV exposure.
6. Tested at T=25°C.
7. Peak to peak non-uniformity test based on an average of 185 x 185 blocks.
8. Average non-illuminated signal with respect to over clocked horizontal register signal.
9. Absolute difference between the maximum and minimum average signal levels of 185 x 185 blocks within the sensor.
10. Dark rms deviation of a multi-sampled pixel as measured using the KAF-8300CE Evaluation Board.
11. $20\log(V_{sat}/N)$
12. Gradual variations in hue (red with respect to green pixels and blue with respect to green pixels) in regions of interest of 185 x 185 blocks.
13. Measured per transfer at 80% of V_{sat}.
14. Esat equals the exposure required to achieve saturation. X_b represents the number of Esat exposures the sensor can tolerate before failure. X_b characterized at 25 °C.
15. Video level DC offset with respect to ground at clamp position. Refer to Pixel Timing Diagram Figure 11.
16. Last stage only. CLOAD = 10pF. Then $f_{-3dB} = (1 / (2\pi * R_{OUT} * C_{LOAD}))$.
17. Amount of artificial signal due to H1 coupling.
18. Sampling plan defined as "die" indicates that every device is verified against the specified performance limits. Sampling plan defined as "design" indicates a sampled test or characterization, at the discretion of Kodak, against the specified performance limits.
19. Calculated value subtracting the noise contribution from the KAF-8300CE Evaluation Board.
20. Process optimization has effectively eliminated vertical striations.
21. CTE = 1 - CTI. Where CTE is charge transfer *efficiency* and CTI is charge transfer *inefficiency*. CTI is the measured value.

Typical Performance Curves

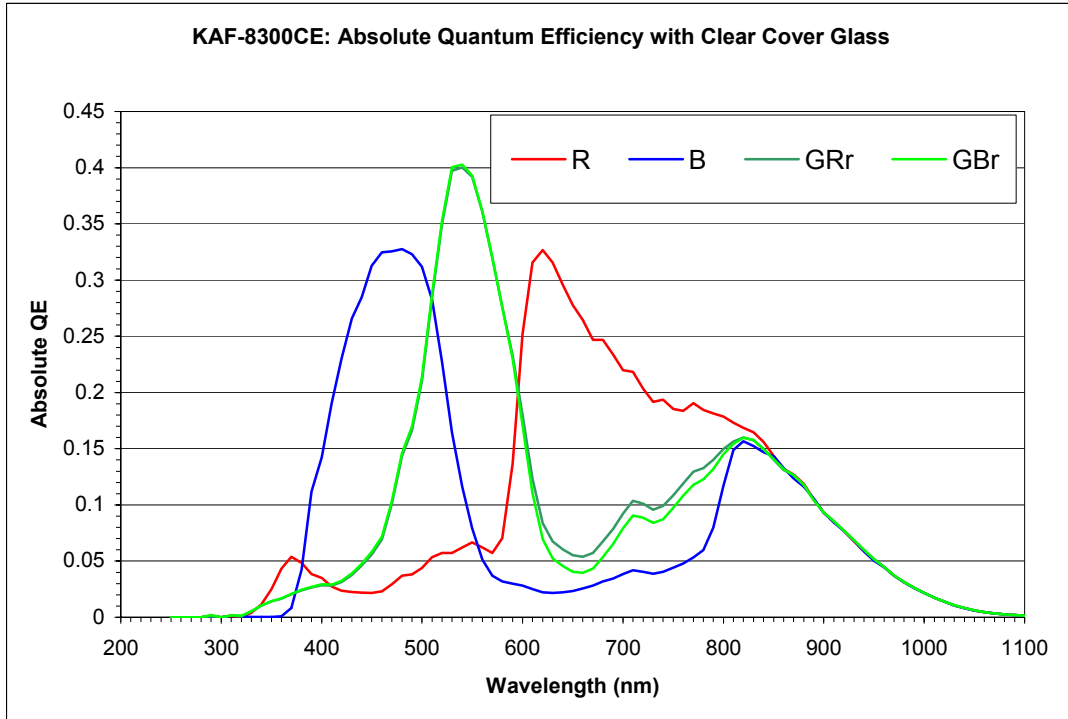


Figure 5 – Typical Quantum Efficiency

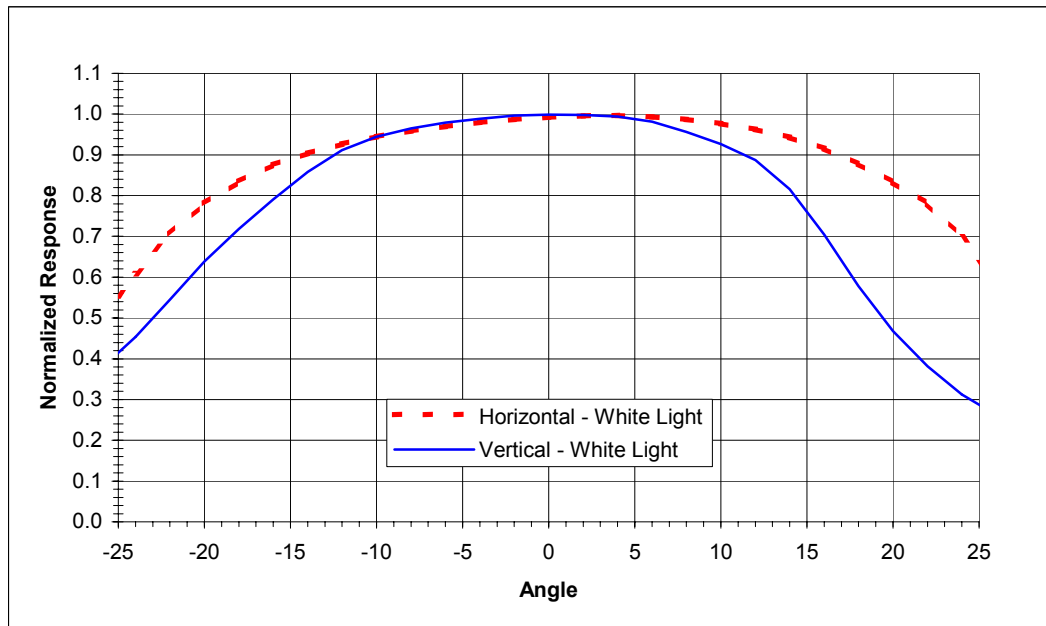


Figure 6 – Typical Angular Response – Clear Cover Glass and White Light Illumination
(Center location of die as shown. Effective optical shift is 6° center-to-edge, along diagonal.)

Defect Definitions

Defect Operational Conditions

The Defect Specifications are measured using the following conditions:

Description	Test Condition	Notes
Integration time (t_{int})	33 msec	Unless otherwise noted

Defect Specifications

Description	Symbol	Definition	Threshold	Maximum Number Allowed
Point defect	BPnt33_7	Dark field, minor, short integration time	7.5 mV	↑ 800 total (6.5.1 Total_Pnts) ↓
Point defect	Bfld_Pnt_D	Dark point in an illuminated field	11%	
Point defect	Bfld_Pnt_B	Bright point in an illuminated field	7%	
Point defect	BPnt33_100	Dark field, major, short integration time	100 mV	↓
Point defect	BPnt33_500	Dark field, major, short integration time	500 mV	0
Point defect	BPnt333_13	Dark field, minor, long integration time, $t_{int}=1/3$ sec	13 mV	32,500 ¹
Point Defect	DR_BPnts	Bright point in the dark reference region	7.5 mV	0
Cluster defect	Total_Clst	A cluster is a group of 2 or more defective pixels that do not exceed the perpendicular pattern defect.		6 total
Cluster defect	Dfld_VPerp	Dark field very long exposure bright cluster where 9 or more adjacent point defects exist, very long integration time, $t_{int}=1$ sec	3.04 mV	0
Cluster Defect – Perpendicular Pattern Defect	Dfld_Perp Bfld_Perp Total_Perp	Three or more adjacent point defects in the same color plane, along a row or column. ²		0
Column defect, illuminated	Bfld_Col_D Bfld_Col_B	A column which deviates above or below neighboring columns under illuminated conditions (>300mV signal) greater than the threshold	1.5% 1.5%	0

Description	Symbol	Definition	Threshold	Maximum Number Allowed
Column defect, darkfield	Dfld_Col2	A column which deviates above or below neighboring columns under non-illuminated or low light level conditions (~10mV) greater than the threshold	1 mV	0
	Dfld_Col4		1 mV	
	Lo_Col_B		1 mV	
	Lo_Col_D		1 mV	
	Lo_Col_B1		1 mV	
	Lo_Col_D1		1 mV	
Row Defect	Dfld_Row	Row defect if row average deviates above threshold	1 mV	0
Streak Test, color	GrnStreak	Maximum defect density gradient allowed in a color bit plane. ⁴	40%	0
	RedStreak		20%	
	BluStreak		20%	
Streak Test, dark	DarkStreak	Maximum defect density gradient allowed in the entire imaging area. ⁵	40%	0
LOD Bright Col, dark	Dfld_LodCol	Defines functionality and uniform efficiency of LOD structure	1.5 mV	0

Notes:

1. This parameter is only a quality metric and these points will not be considered for cluster and point criteria.
2. Green pixels in a red row (GR) are considered a different color plane than the green pixels in a blue row (GB).
3. This note left blank.
4. As the gradient threshold is defined as 8.5 mV maximum across a 16 x 16 pixel region about each pixel. Refer to KAF-8300CE Test Plan for further details.
5. As the gradient threshold is defined as 6 mV maximum across a 50 x 50 pixel region about each pixel. Refer to KAF-8300CE Test Plan for further details.

OPERATION

Absolute Maximum Ratings

Description ⁹	Symbol	Minimum	Maximum	Units	Notes
Diode Pin Voltages	V_{diode}	-17.5	+17.5	V	1,2
Gate Pin Voltages	V_{gate1}	-13.5	+13.5	V	1,3
Overlapping Gate Voltages	V_{1-2}	-13.5	+13.5	V	4
Non-overlapping Gate Voltages	V_{g-g}	-13.5	+13.5	V	5
V1, V2 – LOD Voltages	V_{V-L}	-13.5	+13.5	V	6
Output Bias Current	I_{out}		-30	mA	7
LODT Diode Voltage	V_{LODT}	-13.0	+13.0	V	8
LODB Diode Voltage	V_{LODB}	-18.0	+18.0	V	8
Operating Temperature	T_{OP}	-10	70	°C	10
Guaranteed Temperature of Performance	T_{SP}	0	60	°C	11

Notes:

1. Referenced to pin SUB
2. Includes pins: RD, VDD, VSS, VOUT.
3. Includes pins: V1, V2, H1, H1L, H2, RG, OG.
4. Voltage difference between overlapping gates. Includes: V1 to V2; H1, H1L to H2; H1L to OG; V1 to H2.
5. Voltage difference between non-overlapping gates. Includes: V1 to H1, H1L; V2, OG to H2.
6. Voltage difference between V1 and V2 gates and LODT, LODB diode.
7. Avoid shorting output pins to ground or any low impedance source during operation. Amplifier bandwidth increases at higher currents and lower load capacitance at the expense of reduced gain (sensitivity). Operation at these values will reduce MTTF.
8. V1, H1, V2, H2, H1L, OG, and RD are tied to 0V.
9. Absolute maximum rating is defined as a level or condition that should not be exceeded at any time per the description. If the level or condition is exceeded, the device will be degraded and may be damaged.
10. Noise performance will degrade at higher temperatures.
11. See section for Imaging Performance Specifications.

Power-up Sequence

The sequence chosen to perform an initial power-up is not critical for device reliability. A coordinated sequence may minimize noise and the following sequence is recommended:

1. Connect the ground pins (SUB).
2. Supply the appropriate biases and clocks to the remaining pins.

DC Bias Operating Conditions

Description	Symbol	Minimum	Nominal	Maximum	Units	Maximum DC Current (mA)	Notes
Reset Drain	RD	11.3	11.5	11.7	V	$I_{RD} = 0.01$	
Output Amplifier Return	VSS	1.05	1.25	1.45	V	$I_{SS} = -3.0$	
Output Amplifier Supply	VDD	14.5	15.0	15.5	V	$I_{OUT} + I_{SS}$	
Substrate	SUB		GND		V	-0.01	2
Output Gate	OG	-3	-2.8	-2.6	V	0.1	
Lateral Drain	LODT, LODB	9.5	9.75	10.0	V	0.2	2
Video Output Current	I_{OUT}	-3	-5	-8	mA		1

Notes:

1. An output load sink must be applied to VOUT to activate output amplifier – see Figure 3.
2. Maximum current expected up to saturation exposure (Esat).

AC Operating Conditions

Clock Levels

Description	Symbol	Level	Minimum	Nominal	Maximum	Units	Effective Capacitance	Notes
V1 Low Level	V1L	Low	-9.5	-9.25	-9.0	V	76 nF	1
V1 High Level	V1H	High	2.4	2.6	2.85	V		1
V2 Low Level	V2L	Low	-9.5	-9.25	-9.0	V	81 nF	1
V2 High Level	V2H	High	2.4	2.6	2.8	V		1
RG, H1, H2, amplitude	RG_{amp} $H1_{amp}$ $H2_{amp}$	Amp	5.5	6.0	6.5	V	$RG = 7 \text{ pF}$ $H1 = 224 \text{ pF}$ $H2 = 168 \text{ pF}$	1
H1L, amplitude	$H1L_{amp}$	Amp	7.5	8.0	8.5	V	7 pF	1
H1 Low Level	$H1_{low}$	Low	-4.7	-4.5	-4.3	V		1
H1L Low Level	$H1L_{low}$	Low	-6.7	-6.5	-6.3	V		
H2 Low Level	$H2_{low}$	Low	-5.2	-5	-4.8	V		
RG Low Level	RG_{low}	Low	1.8	2.0	2.2	V		1

Notes:

1. All pins draw less than 10 μ A DC current. Capacitance values relative to SUB (substrate).

Clock Voltage Detail Characteristics (Note 1)

Description	Symbol	Min	Nom	Max	Units	Notes
V1 High-level variation	V1 _{HH}	-	0.50	1	V	High-level coupling
V2 High-level variation	V2 _{HL}	-	0.28	1	V	High-level coupling
V2 Low-level variation	V2 _{LH}	-	0.46	1	V	Low-level coupling
V1 Low-level variation	V1 _{LL}	-	0.14	1	V	Low-level coupling
V1-V2 Cross-over	V1 _{CR}	-2	-0.5	1	V	Referenced to ground
H1 High-level variation	H1 _{HH}	-	0.30	1	V	
H1 High-level variation	H1 _{HL}	-	0.07	1	V	
H1 Low-level variation	H1 _{LH}	-	0.16	1	V	
H1 Low-level variation	H1 _{LL}	-	0.25	1	V	
H2 High-level variation	H2 _{HH}	-	0.40	1	V	
H2 High-level variation	H2 _{HL}	-	0.06	1	V	
H2 Low-level variation	H2 _{LH}	-	0.10	1	V	
H2 Low-level variation	H2 _{LL}	-	0.27	1	V	
H1 – H2 Cross-over	H1 _{CR1}	-3	-1.23	0	V	Rising side of H1
H1 – H2 Cross-over	H1 _{CR2}	-3	-0.59	0	V	Falling side of H1
H1L High-level variation	H1L _{HH}	-	0.64	1	V	
H1L High-level variation	H1L _{HL}	-	0.32	1	V	
H1L Low-level variation	H1L _{LH}	-	0.27	1	V	
H1L Low-level variation	H1L _{LL}	-	0.23	1	V	
H1L – H2 Cross-over	H1L _{CR1}	-1	-	-3	V	Rising side of H1L
RG High-level variation	RG _{HH}	-	0.19	1	V	
RG High-level variation	RG _{HL}	-	0.20	1	V	
RG Low-level variation	RG _{LH}	-	0.11	1	V	
RG Low-level variation	RG _{LL}	-	0.30	1	V	

Notes:

1. H1, H2 clock frequency: 28MHz. The maximum and minimum values in this table are supplied for reference. The actual clock levels were measured using from the KAF-8300CE Evaluation Board. Testing against the device performance specifications is performed using the nominal values.

Timing Requirements

Description	Symbol	Minimum	Nominal	Maximum	Units	Notes
H1, H2 Clock Frequency	f_H			28	MHz	1, 2
V1, V2 Clock Frequency	f_V			125	kHz	2
Pixel Period (1 Count)	t_e	35.7			ns	2
H1, H2 Setup Time	t_{HS}	1			μ s	
H1L – VOUT Delay	t_{HV}		3		ns	
RG – VOUT Delay	t_{RV}		1		ns	
Readout Time	$t_{readout}$	340.2			ms	4, 5
Integration Time	t_{int}					3, 4
Line Time	t_{line}	132.2			μ s	4
Flush Time	t_{flush}	21.23			ms	6

Notes:

1. 50% duty cycle values.
2. CTE will degrade above the nominal frequency.
3. Integration time is user specified.
4. Longer times will degrade noise performance.
5. $t_{readout} = t_{line} * 2574$ lines.
6. See Figure 15 for a detailed description.

Clock Switching Characteristics (Note 1)

Description	Symbol	Min	Nom	Max	Units	Notes
V1 Rise Time	t_{V1r}	-	0.26	1	us	3
V2 Rise Time	t_{V2r}	-	0.55	1	us	3
V1 Fall Time	t_{V1f}	-	0.43	1	us	3
V2 Fall Time	t_{V2f}	-	0.31	1	us	3
V1 Pulse Width	t_{V1w}	5.0	-	-	us	4, 5
V2 Pulse Width	t_{V2w}	3.0	-	-	us	4, 5
H1 Rise Time	t_{H1r}	-	9.0	10	ns	3
H2 Rise Time	t_{H2r}	-	6.9	10	ns	3
H1 Fall Time	t_{H1f}	-	5.8	10	ns	3
H2 Fall Time	t_{H2f}	-	5.4	10	ns	3
H1 – H2 Pulse Width	t_{H1w}, t_{H2w}	14	18	22	ns	
H1L Rise Time	t_{H1Lr}		1.8	4	ns	3
H1L Fall Time	t_{H1Lf}		2.5	4	ns	3
H1L Pulse Width	t_{H1Lw}	14	19.0	22	ns	
RG Rise Time	t_{RGr}	-	2.0	4	ns	3
RG Fall Time	t_{RGf}	-	2.2	4	ns	3
RG Pulse Width	t_{RGw}	-	6.7	-	ns	2

Notes:

1. H1, H2 clock frequency: 28MHz. The maximum and minimum values in this table are supplied for reference. The actual clock timing was measured using from the KAF-8300CE Evaluation Board. Testing against the device performance specifications is performed using the nominal values.
2. RG should be clocked continuously.
3. Relative to the pulse width (based on 50% of high/low levels).
4. CTE will degrade above the nominal frequency.
5. Longer times will degrade noise performance.

Pin Capacitance

Parameter	Value (typical)	Units
$C_{\Phi V1}$	61	nF
$C_{\Phi V12}$	15	nF
$C_{\Phi V2}$	67	nF
$C_{\Phi H1}$	153	nF
$C_{\Phi H12}$	36	nF
$C_{\Phi H2}$	97	nF
$C_{\Phi H1L}$	7	nF
R_{H1LH1}	52	Kohms

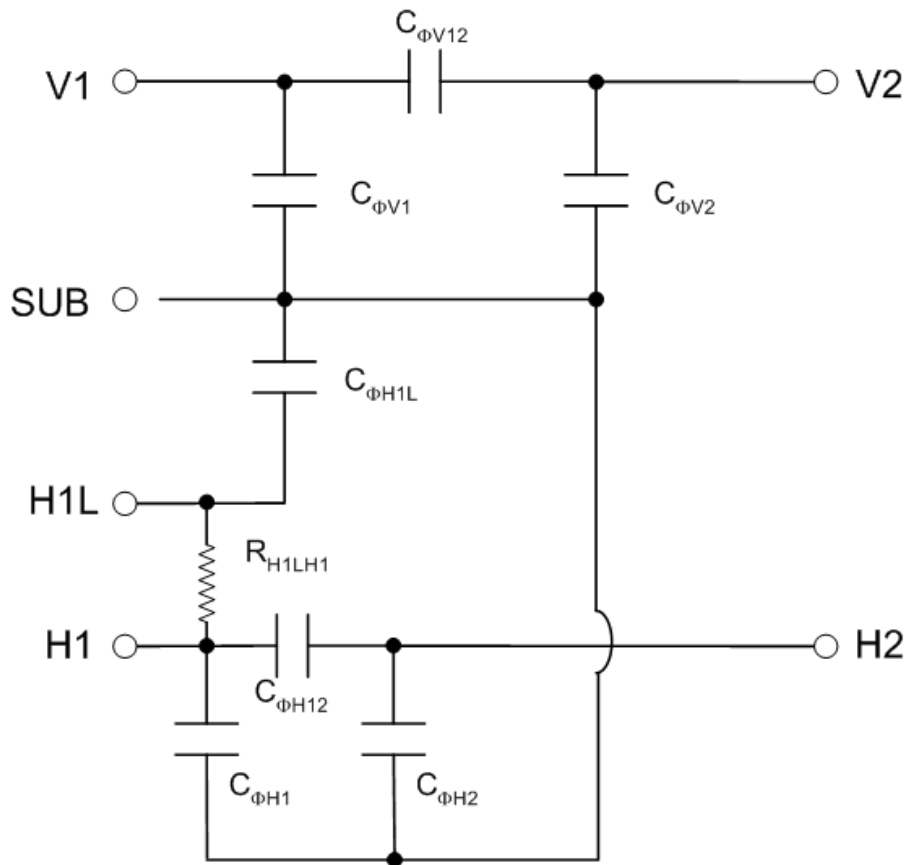


Figure 7 –Device Transfer Clock Equivalent Circuit

Frame Timing

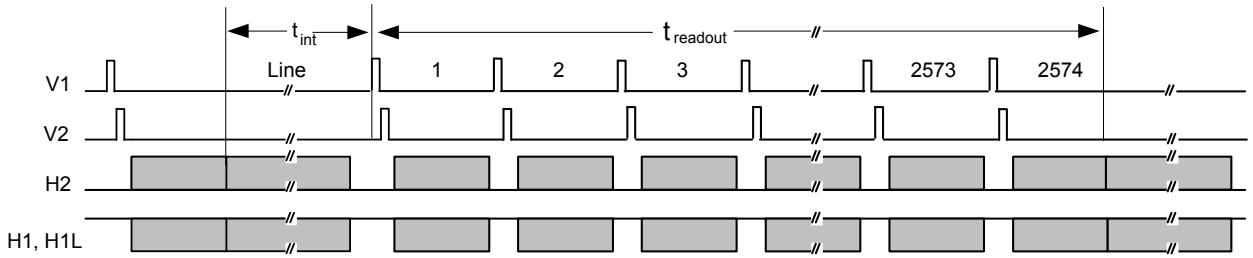


Figure 8 – Frame Timing (minimum)

Frame Timing Edge Alignment

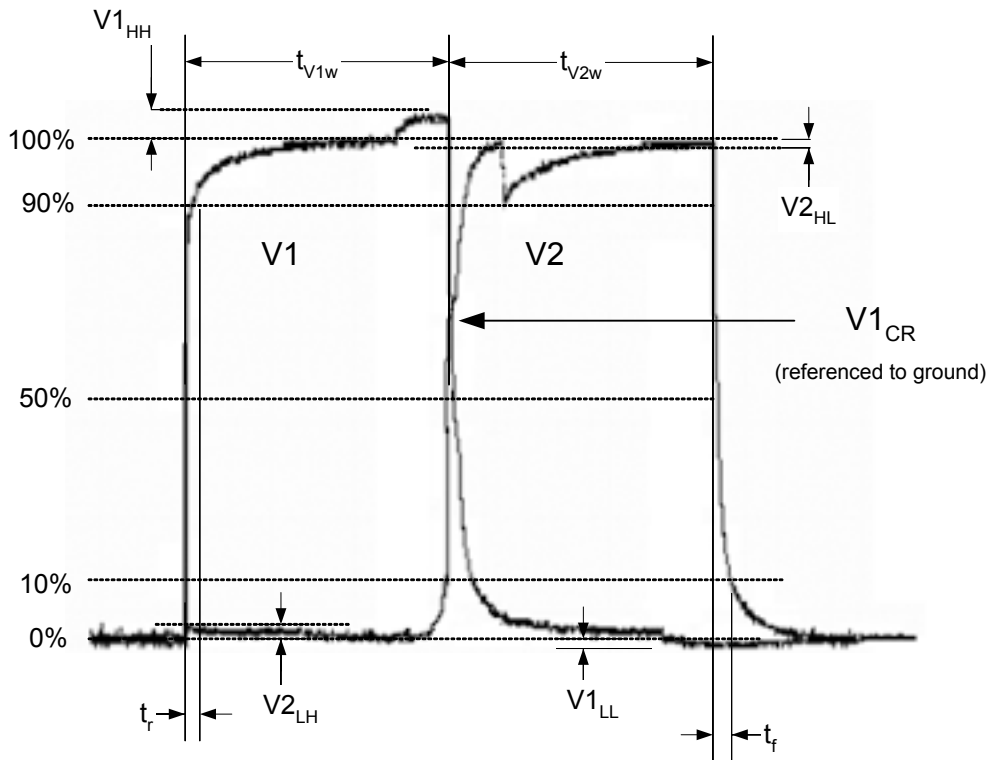
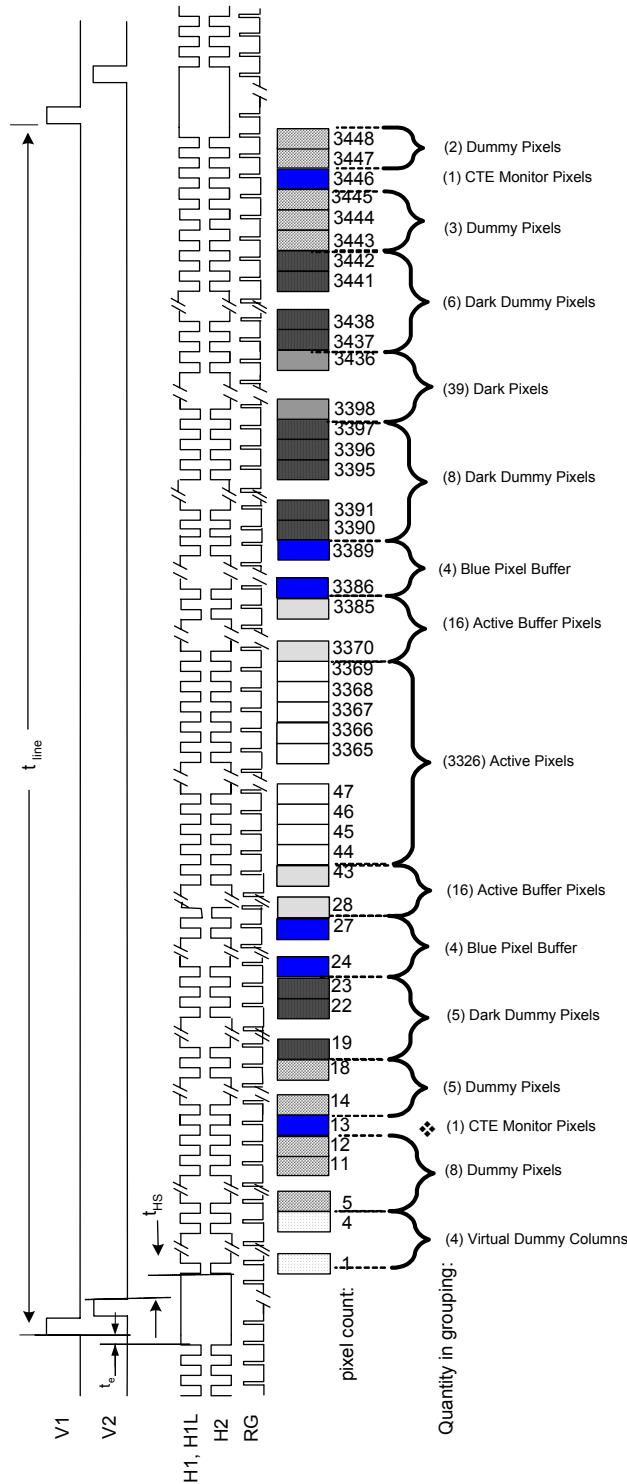


Figure 9 – Frame Timing Edge Alignment

LINE TIMING

Line Timing



KAF-8300CE has 2574 lines (rows) in a single frame.
Line shown above represents the device output for lines 1164-1411 only.

The device output for the other lines are detailed below:

- *** Lines 27 - 30 and 2551 - 2554 are lines mostly composed of blue photoactive buffer pixels.
- ** Lines 31 - 46 and 2555 - 2570 are lines mostly composed of photoactive buffer pixels.
- * Lines 7-18 are lines mostly composed of dark reference pixels.
- *** Lines 1 - 6, 19-26, and 2571 - 2574 are lines mostly composed of dark dummy pixels and are not to be used for imaging purposes or as a dark reference.

❖ For lines 1412 thru 2570 are as shown above with the following exception: pixel 13 are denoted as a dark dummy pixels for these lines.

❖ For lines 1 thru 1163 are as shown above with the following exception: pixel 13 are denoted as a test pixel, of which all are dark dummy except for one photoactive pixel for which row location may vary.

Figure 10 – Line Timing

PIXEL TIMING

Pixel Timing

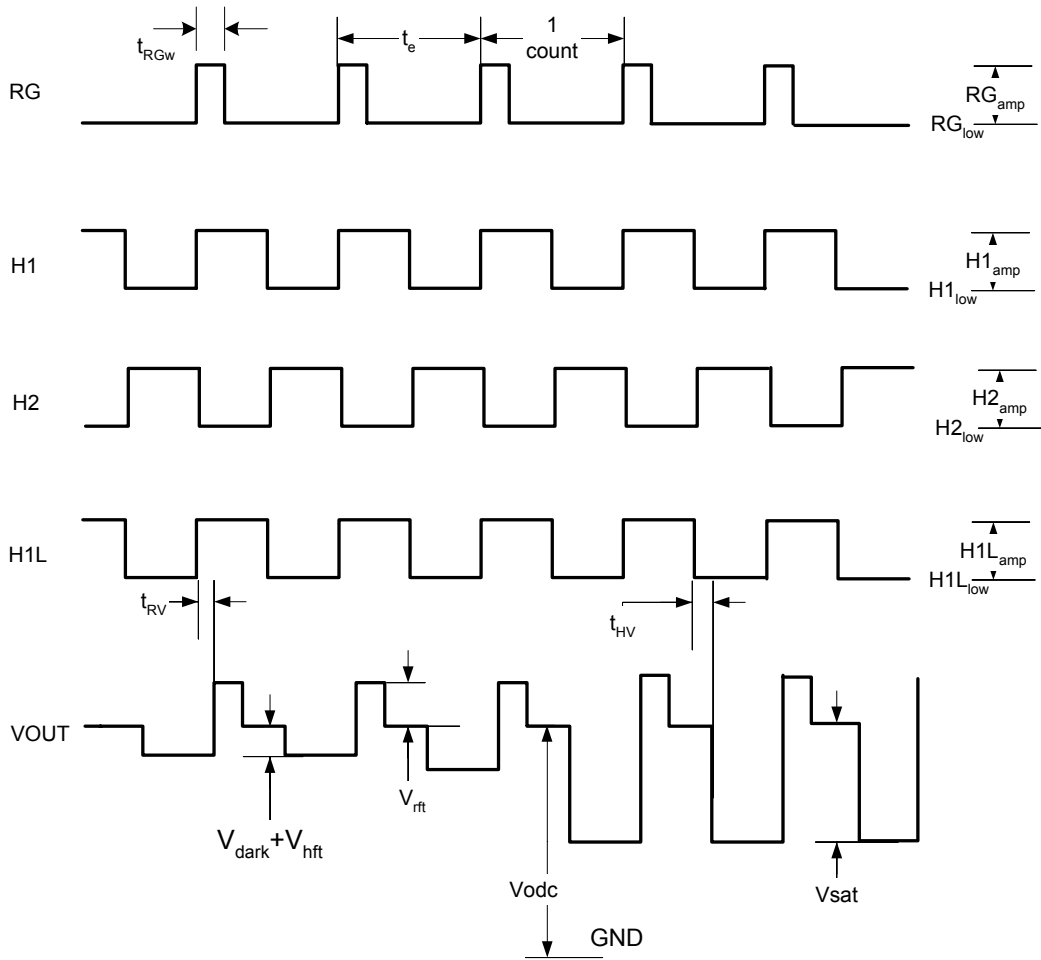


Figure 11 – Pixel Timing

Pixel Timing Detail

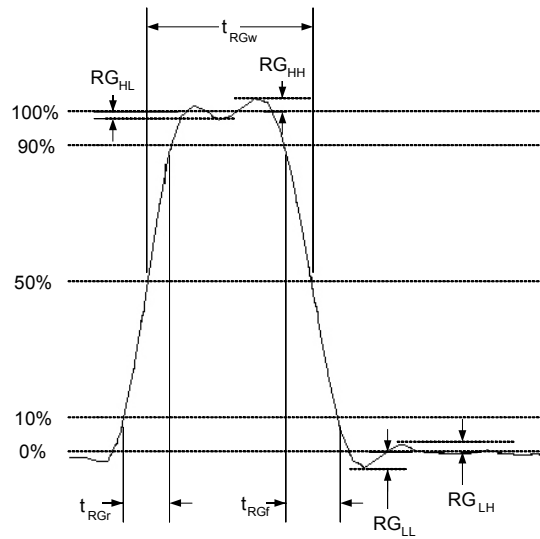


Figure 12 – Pixel Timing Detail

Pixel Timing Edge Alignment

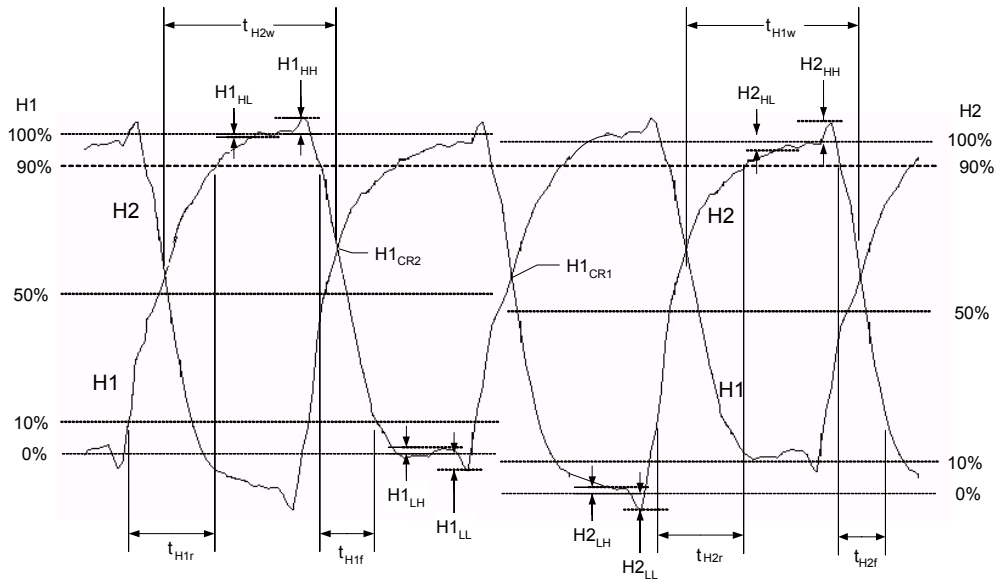


Figure 13 – H1 and H2 Edge Alignment

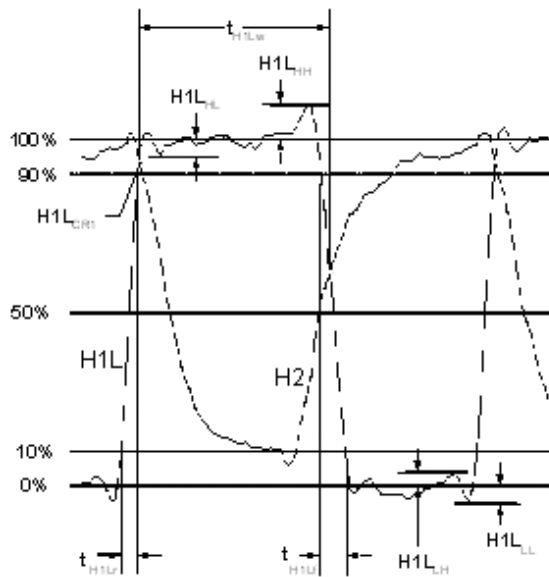


Figure 14 – H1L and H2 Edge Alignment

MODE OF OPERATION

Power-up Flush Cycle

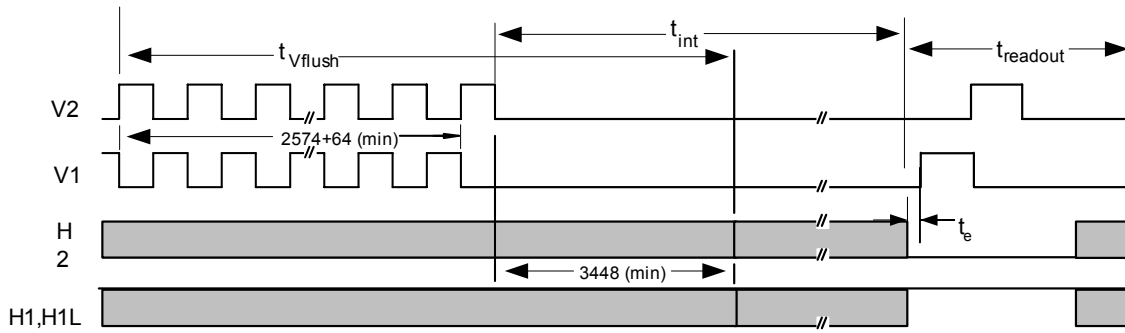


Figure 15 – Power-up Flush Cycle

STORAGE AND HANDLING

Environmental Conditions

Short Term Storage (< 1 year storage)

Assembled devices, in their first level packing container, should be stored indoors, in a dust-free, enclosed environment with the conditions described in the table below. The first level packing includes the tray and a single barrier bag. A fully-sealed bag under vacuum not necessary. Purpose of the barrier bag is to limit dust exposure.

Description	Symbol	Minimum	Maximum	Units	Notes
Humidity	RH	5	90	%	1
Storage Temperature	T _{ST}	-20	80	°C	2

Notes:

1. T=25°C. Excessive humidity will degrade MTTF.
2. Storage toward the maximum temperature will accelerate color filter degradation.

Long Term Storage

Assembled devices stored for longer than 1 year are considered to be in long-term storage. When long-term storage is anticipated, the devices in carriers should be placed into moisture proof, vacuum-sealed, anti-static bags or a similar moisture proof enclosure to prevent the deterioration of the lead pins. The moisture proof package should be stored indoors, in a dust free, enclosed environment with the following conditions:

Description	Condition
Time Limit	1 to 5 years
Temperature	20°C to 40°C
Relative Humidity	< 60%

Caution:

Long-term storage, if done improperly, may cause the lead pins to oxidize or corrode which may affect the pin solderability, or the electrical characteristics may deteriorate. When devices are stored for time periods in excess of 1 year, the pin solderability should be confirmed prior to use. Additionally, the electrical characteristics should be confirmed, as necessary, prior to use.

Note:

For devices from Long-Term Storage Image Sensor Solutions can offer a retest service for a reasonable fee.

Handling Conditions

ESD

1. This device contains limited protection against Electrostatic Discharge (ESD). Devices should be handled in accordance with strict ESD procedures for Class 2 JESD22 Human Body Model ($\leq 2000V$) and Class B Machine Model ($\leq 200V$). Refer to Application Note MTD/PS-0224, Electrostatic Discharge Control, for proper handling and grounding procedures. This application note also contains recommendations for workplace modifications for the minimization of electrostatic discharge.
2. Devices are shipped in static-safe containers and should only be handled at static-safe workstations.

Soldering recommendations

1. Olympus Pb-free soldering procedure is defined as a partial heating method as follows:
 - a. Using a 80 Watt ESD-safe soldering iron,
 - b. 350 °C soldering iron tip temperature for less than 3 seconds per pin,
 - c. Allow the part to cool to room temperature,
 - d. 350 °C soldering iron tip temperature for less than 3 seconds per pin.
2. For circuit board repair, or de-soldering an image sensor, do not use solder suction equipment. In any instance, care should be given to minimize and eliminate electrostatic discharge.

Cover glass care and cleanliness

1. Devices are shipped with the cover glass region covered with a protective tape. The tape should be removed upon usage.

The cover glass is highly susceptible to particles and other contamination. Touching the cover glass must be avoided. See ISS Application Note MTD/PS-0237, Cover Glass Cleaning for Image Sensors, for further information.

Environmental Exposure

1. Do not expose to strong sun light for long periods of time. The color filters may become discolored. Long time exposures to a static high contrast scene should be avoided. The image sensor may become discolored and localized changes in response may occur from color filter aging.
2. Exposure to temperatures exceeding the absolute maximum levels should be avoided for storage and operation. Color filter performance may be degraded. Failure to do so may alter device performance and reliability.
3. Avoid sudden temperature changes.
4. Exposure to excessive humidity will affect device characteristics and should be avoided. Failure to do so may alter device performance and reliability.
5. Avoid storage of the product in the presence of dust or corrosive agents or gases.
6. Long-term storage should be avoided. Deterioration of lead solderability may occur. It is advised that the solderability of the device leads be re-inspected after an extended period of storage, over one year.

VISUAL MECHANICAL CRITERIA

Visual Mechanical Specifications

Laser Mark

Item	Description
Device Name	KAF-8300CE
Lot Number	<i>annn</i> – one alpha character and a 3 numeric field to designate production lot description that is used to track material through the production facility. The “nnn” field is a sequential number that can range from “000” through “999”. The “a” field is also a sequential field and increments to the next alphabet character when the “nnn” field is incremented past the “999” value.
Serial Number	<i>nnn</i> – a numeric field containing a maximum of three characters denoting a unique unit identifier for a device from the before mentioned production lot. The start of the sequence starts with “1”. “001” is not a valid marking.

All markings shall be readable, consistent in size with no unusual debris left on the package.

Assembly/Package Integrity

Criteria	Description
Cracks	None allowed
Corner and edge chip-outs	None – exceeding 0.020” (0.50mm)
Chip-outs exposing buried metal traces	None allowed
Chip-outs, other	None allowed deeper than 50% of the ceramic layer thickness in which it resides
Scratches	None – that exceed 0.20” (0.50mm) in the major dimension and are deeper than 50% of the ceramic layer thickness in which it resides.
Lead conditions	No bent, missing, damaged, or short leads. No lead cut-off burrs exceeding 0.005” (0.13mm) in the dimension away from the lead.
Internal Appearance And Die Condition	<p>Local Non-Uniformity Local Non-Uniformity region (LNU) is allowed whose size is not greater than 200 μm^2 within the effective image area. Inspection equipment for these steps are performed using a microscope 7-50X and direct lighting (ring-light). LNU is described as a spot or streak that tends to change from light to dark in appearance as the operator rotates the part under <i>angled</i> lighting conditions. These non-uniformities are not visible or very hard to see under direct lighting. They tend to disappear or become much less visible under higher magnification.</p> <p>Conditions Other than LNU: No scratches, digs, contamination, marks, or blemishes that is attached to the die that touches 9 or more pixels in the effective image area. No loose contamination allowed when viewed at 7X and 50X magnification.</p> <p>No scratches, digs, contamination, marks, or blemishes greater than 10μm are allowed on the bottom side of the cover glass region that is contained in or extends into the effective image area. Tools used to verify are 7X and 50X magnification.</p>

Glass	
Criteria	Description
Tilt	The reject condition is when the glass is incorrectly seated on the package or is not parallel to glass seal area. ("parallel" is defined as 0.25mm maximum end to end).
Seal	Glass seal must be greater than 50% of the width of the epoxy bond line and must not extend over the ceramic package.
Alignment	There are 4 "+" fiducials on the corners the die that must not be covered by the epoxy light shield. The 4 "+" marks must be in total view when the lid is placed looking directly down on the device with a microscope. All 4 "+" alignment marks are required to be visible in their entirety with a zero clearance tolerance.
Chips	None allowed.
Appearance	No fogged cover glass allowed.
Contamination	No immobile scratches, digs, contamination, marks, or blemishes are allowed on the cover glass region that is contained in or extends into the effective image area. Within the effective image area, the limit for such conditions is 10um or less. This criterion pertains to either the top or the bottom glass surface. Tools used to verify are 7X and 50X magnification.

Glass Cover Tape	
Criteria	Description
Placement	Per the following drawing. Shall not extend beyond the edge of the glass lid (tab excluded).
Tab Location	Located toward the pin 1/pin 40 end of the package.
Damage	Wrinkles and tears are not allowed
Bubbles	No bubbles allowed under the tape in the effective image area of the cover glass that are larger than 5mm.
Cover glass tape edge	Edges must be sealed completely
Between Cover Glass and Tape	No trapped contamination between the tape and the top of the cover glass that is within the effective image area when viewed at 7X and 50X magnification.
Contamination	After removal of the cover glass tape, no mark, blemish, or remnants of glue shall be visible on in the effective image area of the cover glass after proper removal of the cover glass tape.
Scratches	The cover tape application equipment will make slight scratches on the lid tapes. This is allowed

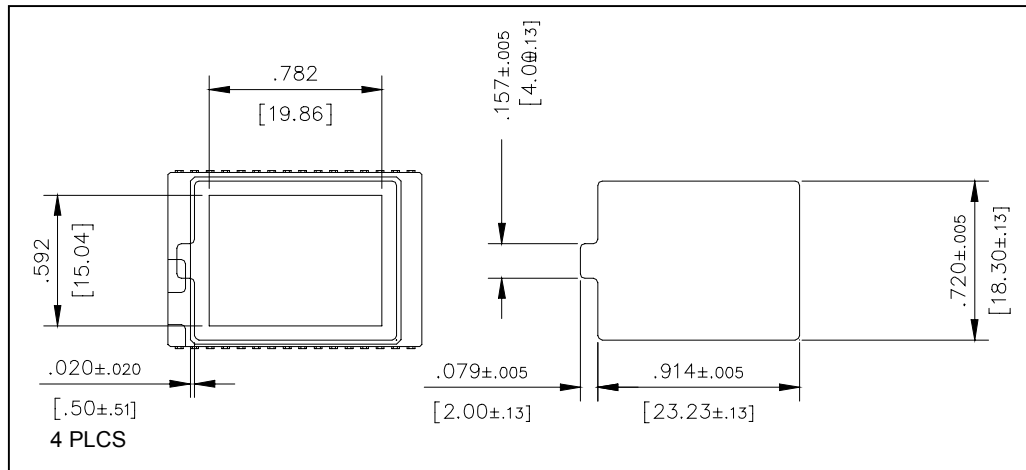


Figure 16 – Cover glass protection tape

Placement in Tray – (see following figure)

Criteria	Description
Position	“Dead Bug” with leads up for an upright tray.
Pin 1 location	Faces away from the corner notch in the tray.
Number of devices per tray	32 maximum
Number of trays per shipping bundle	6 maximum
Dimension of tray, outside	135.9 mm x 315.0 mm +/- 0.25 mm

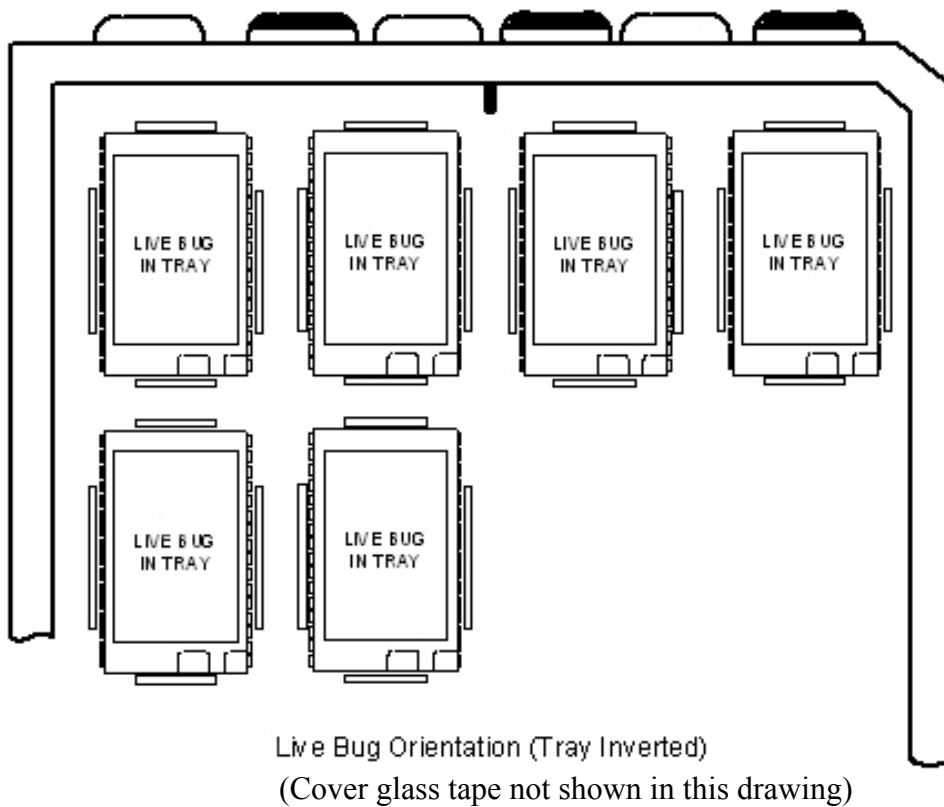
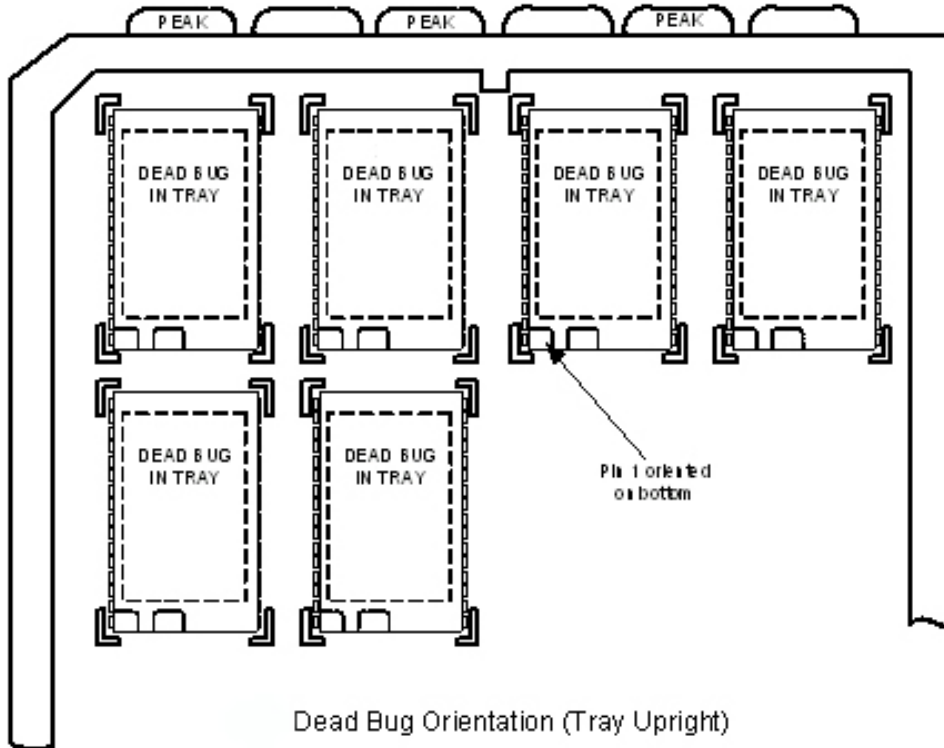


Figure 17 – Package/Tray Orientation

Package Drawings

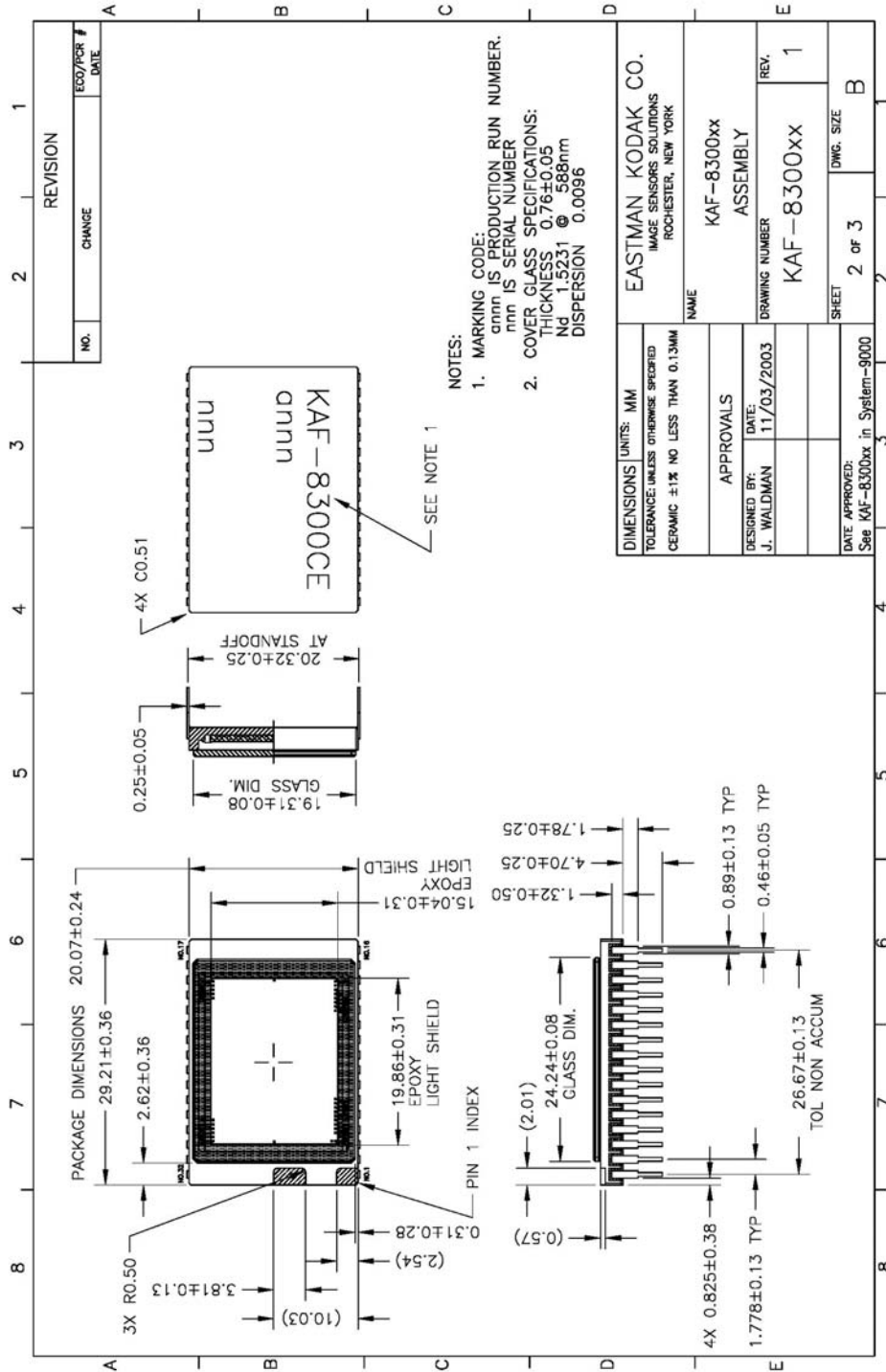


Figure 18 – Package Drawing

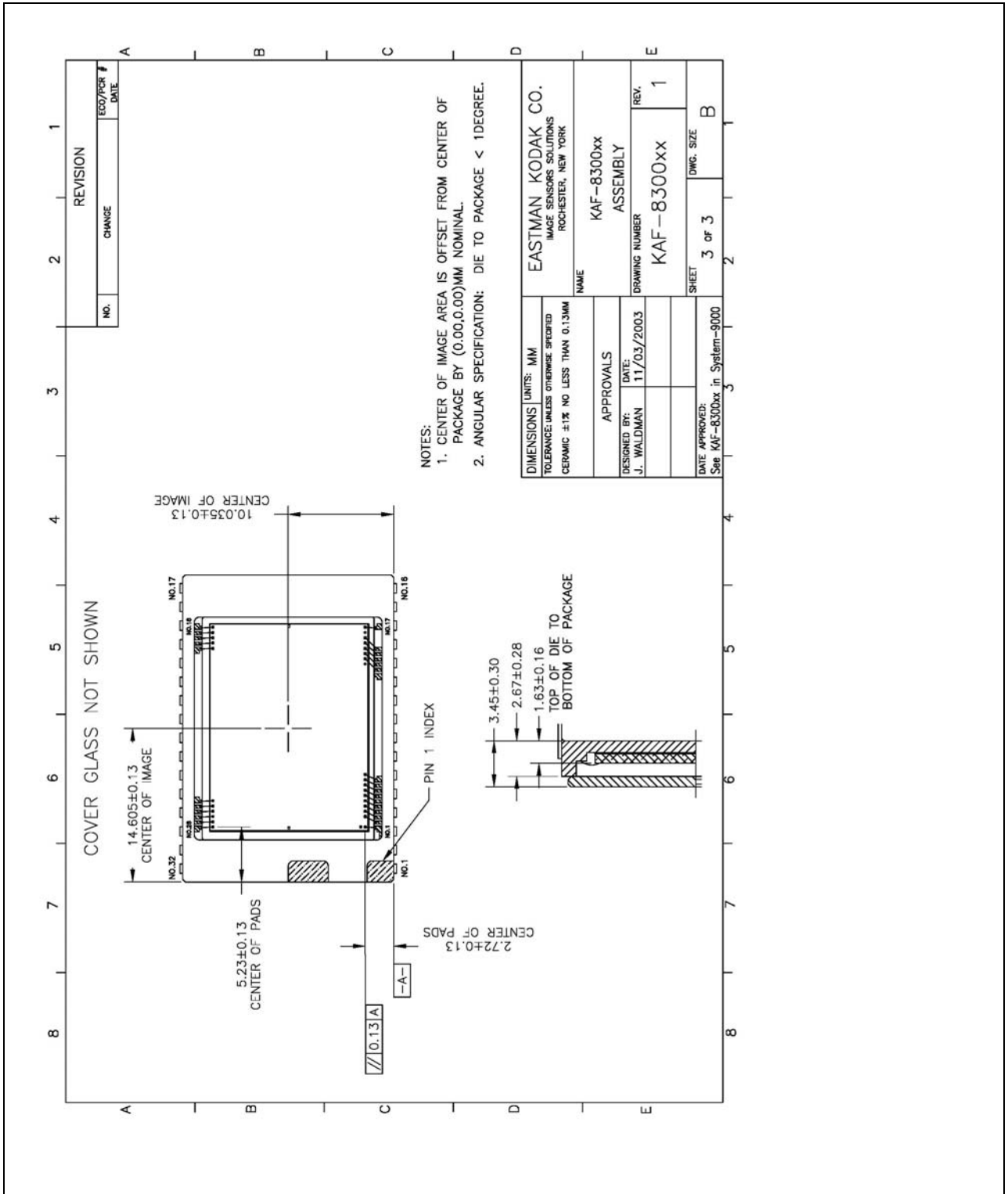


Figure 19 – Die to Package Alignment, Device Marking

Glass Transmission

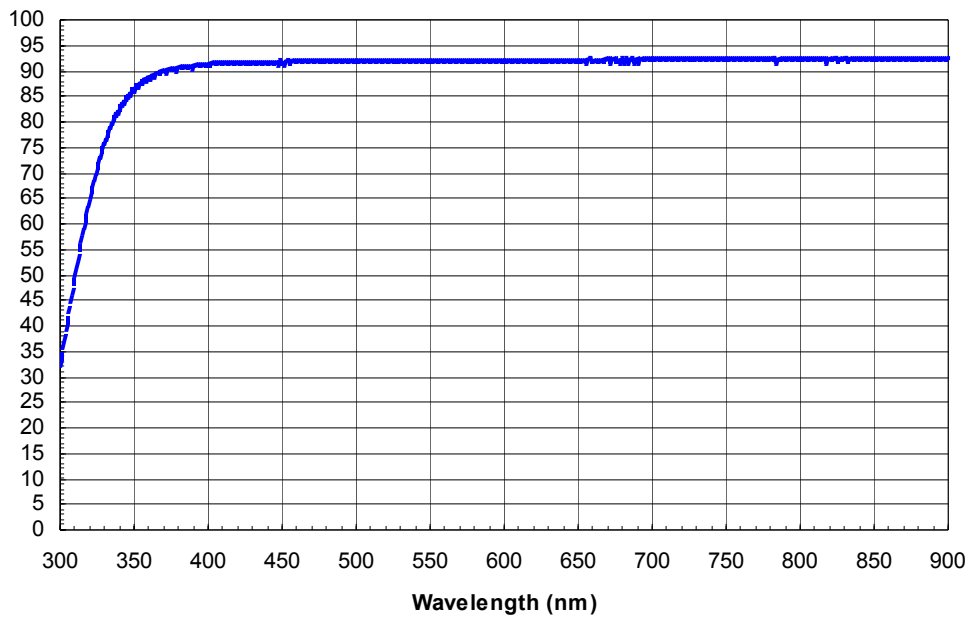


Figure 20 – Glass Transmission

Shipping Configuration, High Vol.

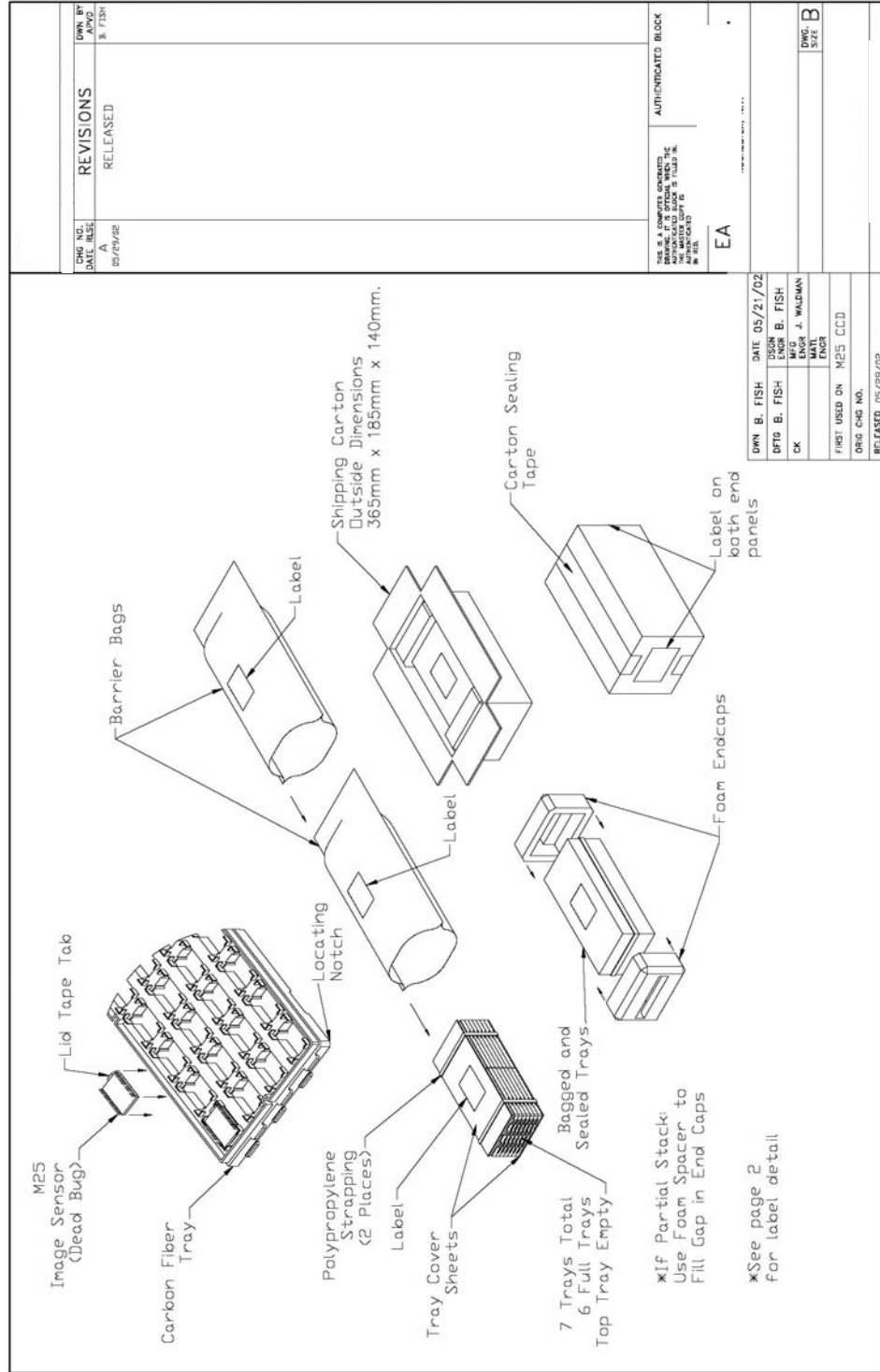



Figure 21 – Packing materials Configuration

Kodak KAF-8300CE Image Sensor	
LOT	QTY
<i>annn</i>	<i>nnn</i>
<i>annn</i>	<i>nnn</i>
<i>annn</i>	<i>nnn</i>
<hr/>	
PART NUMBER	4H0467
	Eastman Kodak Company Image Sensor Solutions Rochester, NY 14660-2010 (585) 722 - 4385
	PIN 2E8062

The contents of the shipping container are described on the shipping label shown above. In the “LOT” column, “annn” represents an alpha character followed by a three character numeric field that denotes the production run number contained in the shipping container. In the “QTY” column, the “nnn” represents a numeric field that represents the quantity of devices from that lot in the shipping container.

Figure 22 – Packing materials, label description

QUALITY ASSURANCE AND RELIABILITY

Quality Strategy: All image sensors will conform to the specifications stated in this document. This will be accomplished through a combination of statistical process control and inspection at key points of the production process. Typical specification limits are not guaranteed but provided as a design target. For further information refer to ISS Application Note MTD/PS-0292, Quality and Reliability.

Replacement: All devices are warranted against failure in accordance with the terms of Terms of Sale. This does not include failure due to mechanical and electrical causes defined as the liability of the customer below.

Liability of the Supplier: A reject is defined as an image sensor that does not meet all of the specifications in this document upon receipt by the customer.

Liability of the Customer: Damage from mechanical (scratches or breakage), or other electrical misuse of the device beyond the stated absolute maximum ratings, which occurred after receipt of the sensor by the customer, shall be the responsibility of the customer.

ESD Precautions: Devices are shipped in static-safe containers and should only be handled at static-safe workstations. See ISS Application Note MTD/PS-0224, Electrostatic Discharge Control, for handling recommendations.

Reliability: Information concerning the quality assurance and reliability testing procedures and results are available from the Image Sensor Solutions and can be supplied upon request.

Test Data Retention: Image sensors shall have an identifying number traceable to a test data file. Test data shall be kept for a period of 2 years after date of delivery.

Mechanical: The device assembly drawing is provided as a reference. The device will conform to the published package tolerances.

ORDERING INFORMATION**Available Part Configurations**

Type	Description	Glass Configuration
KAF-8300CE	4H0469 KAF8300ACELM-ANB-C Color with microlens, General Release	Clear, sealed

Please contact Image Sensor Solutions for available part numbers.

Address all inquiries and purchase orders to:

Image Sensor Solutions
Eastman Kodak Company
Rochester, New York 14650-2010
Phone : (585) 722-4385
Fax : (585) 477-4947
E-mail : imagers@kodak.com

All modifications to this specification will be agreed to by both parties in writing.

WARNING: LIFE SUPPORT APPLICATIONS POLICY

Kodak image sensors are not authorized for and should not be used within Life Support Systems without the specific written consent of the Eastman Kodak Company. Product warranty is limited to replacement of defective components and does not cover injury or property or other consequential damages.

REVISION CHANGES

Revision Number	Release Date	Description of Changes
1	10/10/04	Original version